2ATENT COOPERATION TRE. JY

From the

INTERNATIONAL SEARCHING AUTHORITY

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		(PCT Rule 43bis.1)	
·	Date of mailing		
		08 JULY 2004 (08.07.2004)	
Applicant's or agent's file reference FP04017	FOR FURTHER A	FOR FURTHER ACTION See paragraph 2 below	
International application No. PCT/KR2004/000729 International filing date 30 MARCH 2004		Priority date(day/month/year) 21 JULY 2003 (21.07.2003)	
International Patent Classification (IPC) or both national classification	ation and IPC		
IPC7 H01L 27/146, H01L 31/10			
Applicant	,		
OPTOMECHA CO., LTD. et al			
citations and explanations supporting such Box No. VI Certain documents cited Box No. VII Certain defects in the international appl Box No. VIII Certain observations on the international Box No. VIII Certain observations on the international Box No. VIII Certain observations on the international Peliminary Examinary examination is made International Preliminary Examining Authority ("IPEA") exception of the IPEA and the chosen IPEA has not opinions of this International Searching Authority will not be sufficiently in the support of the IPEA and the chosen IPEA has not opinions of this International Searching Authority will not be sufficiently in the support of the IPEA and the chosen IPEA has not opinion of this International Searching Authority will not be sufficiently in the support of the IPEA and the chosen IPEA has not opinion of this International Searching Authority will not be sufficiently in the support of the IPEA and the chosen IPEA has not opinion of this International Searching Authority will not be sufficiently in the support of the IPEA and the chosen IPEA has not opinion of this International Searching Authority will not be sufficiently in the support of the IPEA and the chosen IPEA has not opinion of this International Searching Authority will not be sufficiently in the support of the IPEA and the chosen IPEA has not opinion of this IPEA and the chosen IPEA has not opinion of this IPEA and the chosen IPEA has not opinion of this IPEA and the chosen IPEA has not opinion of this IPEA and the chosen IPEA has not opinion of this IPEA and the chosen IPEA has not opinion of this IPEA and the chosen IPEA has not opinion of this IPEA and the chosen IPEA has not opinion of this IPEA and the chosen IPEA has not opinion of this IPEA and the chosen IPEA has not opinion of this IPEA and the chosen IPEA has not opinion of this IPEA and the chosen IPEA has not opinion of this IPEA and the chosen IPEA has not opinion of this IPEA and the chosen IPEA has not opinion of this IPEA and the chosen IPEA has not opin	(a)(i) with regard to no such statement elication all application will be cept that this does not apotified the International so considered.	velty, inventive step or industrial applicability; onsidered to be a written opinion of the oply where the applicant chooses an Authority I Bureau under Rule 66.1bis(b) that written the applicant is invited to submit to the	
IPEA a written reply together, where appropriate, with amenda of Form PCT/ISA/220 or before the expiration of 22 months for further options, see Form PCT/ISA/220.			
3. For further details, see notes to Form PCT/ISA/220.		No. 1 15 28	
Name and mailing address of the ISA/KR	Authorized officer	2014. 12 A PART	
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WRITTEN OPINION OF THE INTERNATIONAL SEARCHING AUTHORITY

international application No.

PCT/KR2004/000729

Box No. 1 Basis of this opinion
·
1. With regard to the language, this opinion has been established on the basis of the international application in the language in which it was filed, unless otherwise indicated under this item.
This opinion has been established on the basis of a translation from the original language into the following language, which is the language of a translation furnished for the purposes of international search (under Rules 12.3 and 23.1(b)).
 With regard to any nucleotide and/or amino acid sequence disclosed in the international application and necessary to the claimed invention, this opinion has been established on the basis of:
a. type of material
a sequence listing
table(s) related to the sequence listing
b. format of material
in wirtten format
in computer readable form
c. time of filing/furnishing
contained in the international application as filed.
filed together with the international application in computer readable form.
furnished subsequently to this Authority for the purposes of search.
In addition, in the case that more than one version or copy of a sequence listing and/or table relating thereto has been filed or furnished, the required statements that the information in the subsequent or additioanl copies is identical to that in the application as filed or does not go beyond the application as filed, as appropriate, were furnished.
4. Additional comments:

WRITTEN OPINION OF THE INTERNATIONAL SEARCHING AUTHORITY

International application No. PCT/KR2004/000729

Box No. V Reasoned statement under Rule 43bis.1(a)(i) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement

Novelty (N)	Claims 1-18	YES
	Claims NONE	NO
Inventive step (IS)	Claims 2-7, 11, 18	YES
	Claims 1,8-10, 12-17	NO
Industrial applicability (IA)	Claims 1-19	YES
	Claims None	NO

2. Citations and explanations:

The documents cited in the International Search Report:

D1: JP 08-43605 A D2: US 6033766 A D3: JP 2003-15275A

The subject matter of Claims 1, 8-10 and 12-17 lacks an inventive step under PCT Article 33(3).

Claims 1, 8-10 and 12-17 of the present invention disclose an image sensor and a method of its fabrication including optical path conversion elements(the tangent line gradient of incident surfaces is formed differently as it moves far away from the center of an image sensor, and is formed into a Reactive ion etching using gray scale mask) formed on a substrate. It is easy for a person skilled in the art to arrive at the invention from the components of an optical device which has a different tilt, wherein the center which is disclosed in D1 and D2 moves far away. In addition, multiple formulas which are disclosed in the above claims are obvious to a person skilled in the art.